

Silenes and Silenoids. 7. The Reactions of Alkylolithium Reagents with Vinyl dimethylfluorosilane

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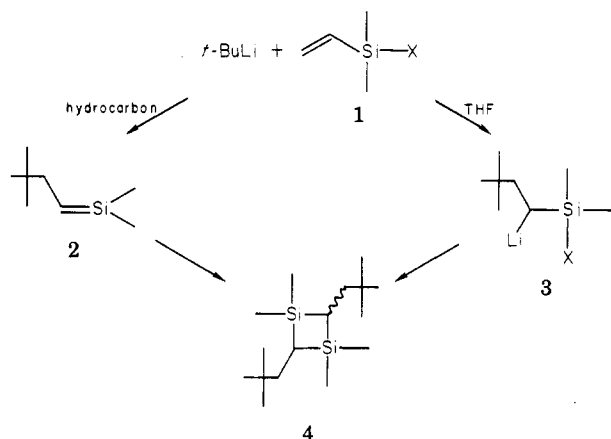
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The reactions of *tert*-butyl-, *sec*-butyl-, and *n*-butyllithium with vinyl dimethylfluorosilane include addition to the double bond giving silene and/or silenoid intermediates, fluorine substitution, and an unprecedented vinyl substitution. For the *tert*-butyllithium reaction product stereochemistry and trapping experiments using both cyclopentadiene and methoxytrimethylsilane show that silenes are not formed in tetrahydrofuran and that in hexane about 67% of the 1,3-disilacyclobutanes obtained arise from silene dimerization while 33% are formed by silenoid coupling. In hexane the order of reactivity for addition *t*-Bu > *sec*-Bu > *n*-Bu is opposite that for fluorine substitution. The vinyl substitution reaction is most significant for secondary alkylolithium reagents including the *tert*-butyllithium adduct to vinyl dimethylfluorosilane, **3** (X = F), and *sec*-butyllithium. Evidence for the formation of vinylolithium or ethylene in the process could not be obtained.

Introduction

The reaction of *tert*-butyllithium with vinyl dimethylchlorosilane, **1** (X = Cl), in hydrocarbon solvents gives rise to 1,1-dimethyl-2-neopentylsilene, **2**, which dimerizes in the absence of trapping reagents to give the corresponding 1,3-disilacyclobutane **4**.¹ The silene can be trapped as its



[4 + 2] cycloadduct with conjugated dienes.² In tetrahydrofuran the silene is apparently not formed, and products arising from the α -lithiosilane **3**, a silenoid intermediate, are obtained.^{2,3} Typically when the dimers **4** have a silene precursor, their *cis/trans* ratio is about 1.1 \pm 0.1 while the ratio is ca. 3 or 4 when the dimers are formed via the α -lithiosilane **3**.^{4,5}

In reactions with **1** (X = Cl), *tert*-butyllithium appears to be unique in producing silene. Both *n*-butyl- and *sec*-butyllithiums give predominantly substitution at silicon to form butyl-substituted silanes.⁴ In contrast, the addition reaction of vinyl dimethylalkoxysilanes, **1** (X = OMe or OEt), with alkylolithium reagents appears to be quite general for hydrocarbon-soluble organolithiums, giving good yields of monosilacyclobutanes from the α -lithioalkoxysilanes.⁶ In an investigation of the effects of leaving groups

Table I. Comparison of the Effects of Reaction Conditions on the Reaction of *tert*-Butyllithium with Vinyl dimethylhalosilanes

expt	1, X =	conditns	1/ <i>t</i> -BuLi ratio	product yields, ^a %			4 cis/trans
				4	5	6 ^b	
1	F	hexane, -78 °C		24	38	10	62/38
2	Cl ²	hexane, -78 °C	1	78	0	0	53/47
3	F	hexane, -78 °C	2	21	42	tr	65/35
4	F	hexane, -78 °C	0.5	57	tr	tr	65/35
5	F	hexane, 25 °C	1	50	tr	tr	64/36
6	Cl ²	hexane, 25 °C	1	46	0	0	54/46
7	F	THF, -78 °C	1	44	1	16	80/20
8	F	THF, -78 °C	2	8	1	56	79/21
9	Cl ⁸	THF, -78 °C	0.5	9	0	39 ^c	75/25

^a Determined by GLC using an internal standard calibration. ^b X = Cl or F depending on substrate. ^c A 15% yield of **6** (X = *t*-Bu) was also obtained.

on silene formation from α -lithiosilanes, Wiberg and co-workers have observed that fluorosilanes are intermediate in reactivity between chlorosilanes and alkoxy-silanes with respect to silene product formation.⁷ With the objective of increasing the generality of our silene generation method we have undertaken a study of the reactions of alkylolithium reagents with vinyl dimethylfluorosilane.

Results

The reaction of *tert*-butyllithium with vinyl dimethylfluorosilane⁸ in hexane at -78 °C gives only a 24% yield of the anticipated 1,3-disilacyclobutanes **4**. The major product, in 38% yield, is the unexpected 1,1-bis(dimethylfluorosilyl)-3,3-dimethylbutane, **5**. In addition 4-(dimethylfluorosilyl)-3,3,6,6-tetramethyl-3-sila-1-heptene, **6**, is obtained in 10% yield. In an effort to determine the source of **5** we carried out the reaction under a variety of experimental conditions. The results are given in Table I along with data for representative experiments with vinyl dimethylchlorosilane.

Vinyl dimethylfluorosilane is clearly the source of the additional dimethylfluorosilyl group in **5**. However, the use of excess **1** (X = F) (experiment 3) does not increase the yield of **5** significantly. When the reaction is carried

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(2) Jones, P. R.; Lim, T. F. O.; Pierce, R. A. *J. Am. Chem. Soc.* **1980**, *102*, 4970-3.

(3) Wiberg, N.; Preiner, G.; Schieda, O. *Chem. Ber.* **1981**, *114*, 2087-98, 3518-32.

(4) Jones, P. R.; White, D. D., unpublished observations.

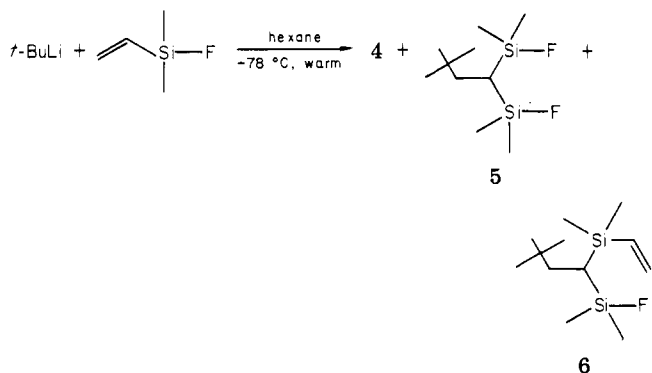
(5) Conlin, R. T.; Bessellieu, M. P.; Jones, P. R.; Pierce, R. A. *Organometallics* **1982**, *1*, 396-7.

(6) Jones, P. R.; Lim, T. F. O.; McBee, M. L.; Pierce, R. A. *J. Organomet. Chem.* **1978**, *159*, 99-110.

(7) Wiberg, N.; Preiner, G.; Schieda, O.; Fischer, G. *Chem. Ber.* **1981**, *114*, 3505-17.

(8) Svoboda, P.; Vaisarova, V.; Chvalovsky, V. *Collect. Czech. Chem. Commun.* **1972**, *37*, 2259-64.

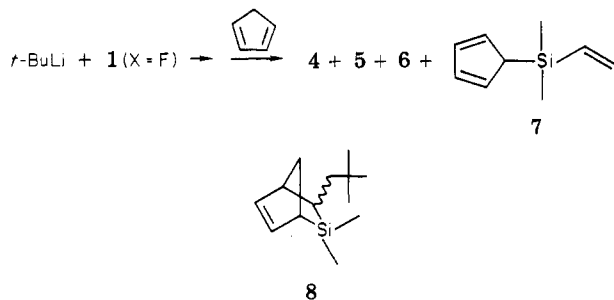
(9) Lim, T. F. O. Doctoral Dissertation, North Texas State University, May, 1977.



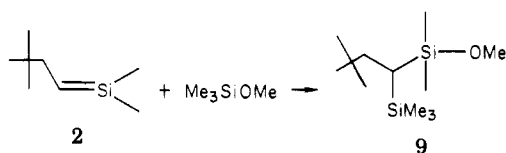
out by using excess *tert*-butyllithium (experiment 4) or under conditions where silene formation is rapid (experiment 5), the yield of 5 decreases in favor of silene dimer formation. In hydrocarbon solvent no products derived from *tert*-butyl substitution at silicon are obtained.

It should be noted that the vinyl dimethylsilyl-substituted product 6 is not obtained in hexane with 1 (X = Cl) (experiment 2 or 6) or with 1 (X = F) in reactions where 5 is not formed. However, 6 is obtained in THF for 1 (X = Cl or F), although only traces of 5 are produced. Compound 6 can arise from the reaction of the silenoid 3 with 1 in THF but may arise from the reaction of 5 with vinyl lithium in hexane. In THF the dimer stereochemistry indicates an α -lithiosilane precursor. The high *cis/trans* ratio of the dimers obtained in THF for 1 (X = F) is comparable with that obtained for 1 (X = Cl) under conditions for which the silenoid intermediate 3 has been shown to be the product precursor.^{2,5}

Silene trapping experiments were conducted in this system. With cyclopentadiene as the trap cyclopentadienyldimethylvinylsilane, 7, and the [4 + 2] silene adducts 8 are obtained. Recently methoxytrimethylsilane



has been shown to be a silene trap comparable in efficiency to HCl.¹⁰ In experiments which employed methoxytrimethylsilane as the silene trap, excellent yields of its silene adduct, 2-methoxy-1,5,5-trimethyl-3-(trimethylsilyl)-2-silahexane, 9, were obtained. The results of the trapping experiments are summarized in Table II.

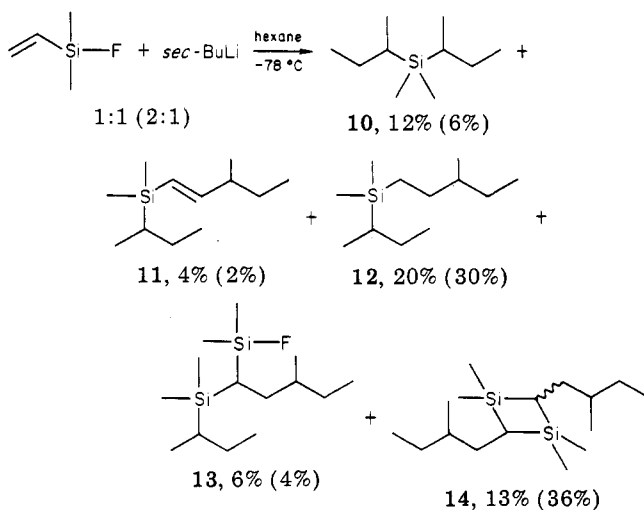


The *exo/endo* ratio for the silnorbornenes 8 is similar to that obtained when 1 (X = Cl)² or thermal sources⁵ are used as the silene precursor. In agreement with Davidson's kinetic results¹⁰ methoxytrimethylsilane is much more efficient than cyclopentadiene as a silene trap. Thus in experiments 14 and 15 the silene dimerization pathway is

diverted, giving 46% yields of 9 and leaving 26–28% of products 4 and 5 derived from the silenoid 3. In THF, (experiment 16) no silene is produced. In all experiments using methoxytrimethylsilane as a silene trap the dimer stereochemistry is consistent with the silenoid pathway. On the basis of these results, we can estimate that approximately two-thirds of the 1,3-disilacyclobutanes 4 obtained from the low-temperature reaction of *tert*-butyllithium with 1 (X = F) in hexane arise via silene dimerization with one-third being formed from the α -lithiosilane 3.¹¹ If we assume this two-thirds to one-third ratio of the silene and silenoid pathways and that 55/45 and 78/22 represent the *cis/trans* ratio of 4 for silene and silenoid dimerization, respectively, the calculated *cis/trans* ratio for 4 in experiments in which both pathways are operative is 63/37, in good agreement with our experimental results.

The results also show that 5 does not have a silene precursor. Overall, the data are only consistent with the production of the bis(dimethylfluorosilyl) compound by the reaction of the α -lithiofluorosilane 3 with vinyl dimethylfluorosilane (experiments 1, 3, 4 and 14, 15). This raises the important question of what happens to the vinyl fragment of 1. While some of it may be giving 6, we have been unable to determine its fate. In an experiment attempting to intercept vinyl lithium using trimethylchlorosilane only a trace of vinyltrimethylsilane was obtained. Similar experiments using acetone or methyl iodide added after the initial addition of *tert*-butyllithium did not give any evidence for vinyl lithium. Experiments designed to trap ethylene as its dibromide showed that ethylene is not produced either during the reaction or during hydrolytic workup. There is always some nonvolatile oligomer produced in these reactions. We must assume that part of this oligomer accounts for the missing vinyl group.

The reaction of 1 with *sec*-butyllithium in hexane at -78 °C gives a more complex mixture. Three new products, 10, 11, and 12, for which analogues were not observed in the *tert*-butyl system are formed.



More than half of the products 10, 11, 12, and 13 (42%) arise from substitution of fluorine on silicon by *sec*-butyllithium. Two products, 10 and 13 (18%), are derived from the vinyl substitution reaction discovered with *tert*-butyllithium. Interestingly product 10 must be formed directly by the reaction of *sec*-butyllithium with starting material.¹² Product 12 clearly arises from hydrolysis of

(10) Davidson, I. M. T.; Wood, I. T. *J. Chem. Soc., Chem. Commun.* 1982, 550.

(11) It should be noted that Wiberg's studies do not differentiate between the silene and silenoid pathways.^{3,7}

Table II. Silene Trapping Experiments in the Reaction of *tert*-Butyllithium with Vinyltrimethylfluorosilane, 1 (X = F)

Cyclopentadiene Trap									
expt	1/ <i>t</i> -BuLi ratio	solvent	product yield, ^a %					4 cis/trans	8 exo/endo
			4	5	6	7	8		
10	1	hexane	19	1	3	14	4	65/35	52/48
11	2	hexane	17	2	2	7	7	66/34	53/47
12	4	hexane	22	7	2	6	2	66/34	56/44
13	1	THF	12	1	23	tr	0	75/25	

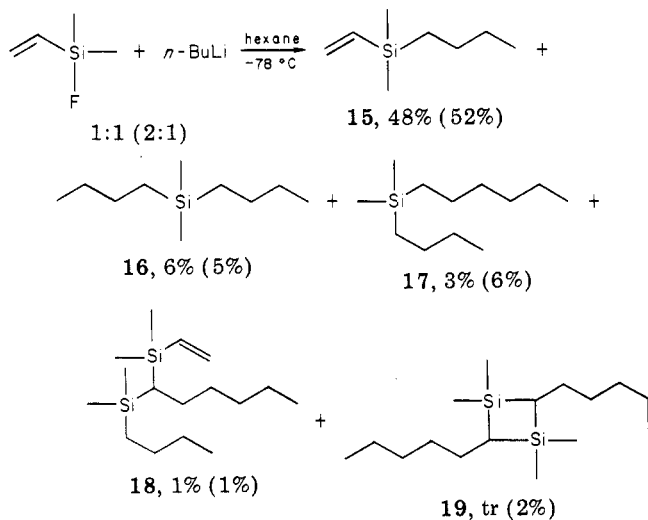
Methoxytrimethylsilane Trap								
expt	1/ <i>t</i> -BuLi ratio	solvent	product yield, %					4 cis/trans
			4	5	6	9	4	
14	1	hexane	22	4	0	46	78/22	
15	2	hexane	10	18	0	46	78/22	
16	1	THF	71	1	3	0	78/22	

^a Yields determined by GLC using an internal standard calibration.

the α -lithio compound 3 (X = *sec*-Bu). Product 11 presumably is formed by the loss of lithium hydride from the same intermediate, a process which we observed previously in the reaction of *tert*-butyllithium with vinyltrimethylsilane.¹ Only a disappointing 13% yield of the silene or silenoid dimer 14 was obtained.

In contrast to the *tert*-butyl system, the use of excess 1 results in an increase in the yield of dimers 14 and a decrease of the vinyl substitution products 10 and 13. The yield of 12 also increases.

In the reaction of 1 with *n*-butyllithium, the major product is the simple fluorine substitution product 15.¹³ Nearly 60% of the products 15, 16, 17, and 18 involve this process in their formation. Only 6% of the vinyl sub-



stitution is obtained; the product 16¹⁴ resulting from reaction of *n*-butyllithium with the vinylsilane 1. Only trace amounts of dimers are produced in the reaction. Doubling the ratio of 1 to *n*-butyllithium has little effect on the product distribution.

For both the *sec*-butyl- and *n*-butyllithium reactions the products obtained in less than 5% yields were only partially characterized. The characterization of 17 and 19, based on mass spectral and NMR data, and that of 11 and 18, based only on mass spectral data, should be regarded as tentative.

(12) To our knowledge replacement of a vinyl group on a vinyl trialkylsilane by an alkylolithium reagent has never been observed.

(13) Buell, G. R.; Corriu, R.; Guerian, C.; Spialter, L. *J. Am. Chem. Soc.* 1970, 92, 7424-8.

(14) Andreev, O. N.; Lavrinovich, L. I. *Zh. Obshch. Khim.* 1968, 38, 2743.

Discussion

Vinyltrimethylfluorosilane undergoes at least three different competitive reactions with alkylolithium reagents: addition to the double bond, fluorine substitution, and an unprecedented vinyl substitution. The order of reactivities in hexane for the addition reaction, *tert*-butyl > *sec*-butyl > *n*-butyl, and the fluorine substitution reaction, *n*-butyl > *sec*-butyl >> *tert*-butyl, might naively be attributed to the steric requirements of the lithium reagent. However, for the concentration ranges employed in our studies, ca. 0.4 M, *tert*-butyllithium is tetrameric, *sec*-butyllithium probably exists as an equilibrium mixture of tetramers and hexamers, and *n*-butyllithium is hexameric.¹⁵ We have no idea of how a vinylhalosilane interacts with or modifies these aggregates. There is evidence that unsaturated molecules coordinate with hexameric alkylolithium aggregates, occupying the two vacant faces of the octahedron formed by the lithium atoms.¹⁶ Such a complexation with the *n*-butyllithium hexamer or the hexameric form of *sec*-butyllithium might give the fluorine substitution reaction an entropic advantage over the addition reaction.

The novel vinyl substitution reaction seems to be most important for secondary alkylolithium reagents. Our results indicate a reactivity order of 3 (X = F) > *sec*-butyllithium > the *sec*-butyl analogue of 3 (X = F) > *n*-butyllithium >>> *tert*-butyllithium. The reaction is observed with vinyltrimethylfluorosilane, but not with vinyltrimethylchlorosilane, and is favored by hydrocarbon solvents. It does not give significant amounts of vinylolithium or ethylene. While intriguing mechanisms involving electron transfer between the alkylolithium reagent and vinyltrimethylfluorosilane¹⁷ or processes involving pentacoordinate organofluorosilanes can be written, such speculations seem inappropriate until more is known about the nature of the species that are actually present in these solutions.

Experimental Section

All reactions were carried out under an atmosphere of dry nitrogen or argon in glassware that was either oven dried and assembled hot or flame dried. Solvents were distilled from lithium aluminum hydride or sodium/potassium alloy immediately prior

(15) Scherr, P. A.; Hogan, R. J.; Oliver, J. P. *J. Am. Chem. Soc.* 1974, 96, 6055-59. Lewis, H. L.; Brown, T. L. *J. Am. Chem. Soc.* 1970, 92, 4664-70.

(16) Oliver, J. P.; Smart, J. B.; Emerson, M. T. *J. Am. Chem. Soc.* 1966, 88, 4101-3. Zenger, R.; Rhine, W.; Stucky, G. *Ibid.* 1974, 96, 6048-55.

(17) Sakurai, H.; Tobita, H.; Nakadaira, Y.; Kabuto, C. *J. Am. Chem. Soc.* 1982, 104, 4288-9. Eisch, J. J.; Beuhler, R. J. *J. Org. Chem.* 1963, 28, 2876-7.

to use. Solutions of alkyllithium reagents (Aldrich) were standardized by using the method of Gilman and Cartledge.¹⁸ Reagents and solvents were transferred by using standard syringe techniques. GLC analyses of the reaction mixtures were carried out by using a Perkin-Elmer Sigma 3 gas chromatograph equipped with a 25-m SE-54 capillary column, flame ionization detection, and a Hewlett-Packard 3390A reporting integrator, with di-*n*-butyl ether as the internal standard.

Samples for characterization were collected from a thermal conductivity gas chromatograph using a 10% OV-17 on 45/60 mesh Supelcoport stationary phase in a 16 ft by $\frac{3}{8}$ in. stainless steel column, programmed at 6 °C/min from 100 to 250 °C. ¹H NMR and ¹³C NMR spectra were obtained on purified samples in capillary tubes inserted in ordinary NMR tubes containing deuteriochloroform or D₂O for the carbon or proton spectra, respectively, using a Perkin-Elmer R24B 60-MHz or JEOL FX-90Q 90-MHz spectrometers. Chemical shifts are reported in parts per million downfield from tetramethylsilane. Mass spectra were obtained by using a Finnigan automated 9500 GC/MS system with 70-eV ionizing voltage.

Elemental analyses were performed by Galbraith Laboratories, Knoxville, TN.

Vinyldimethylfluorosilane, 1 (X = F), was prepared from vinyldimethylchlorosilane¹⁹ using antimony trifluoride with an antimony pentachloride catalyst.⁸ The purified starting material showed the following: IR 1400 (C=C), 1258 (SiCH₃), 872 cm⁻¹ (SiF); ¹H NMR 0.04 (d, 6 H, *J*(H-F) = 17.1 Hz), 5.2–6.3 ppm (m, 3 H); ¹³C NMR -2.0 (*J*(C-F) = 15.9 Hz (SiCH₃)), 135.5 and 133.9 ppm (vinyl carbons).

General Method for the Reaction of 1 (X = Cl or F) with Alkyllithium. Solutions of reactants were cooled to the reaction temperature prior to mixing. To a stirred solution of 2.5 mL (22 mmol) of vinyldimethylfluorosilane in 50 mL of solvent was added dropwise a hydrocarbon solution containing the appropriate amount of the alkyllithium reagent. With the exceptions of the reactions carried out at room temperature, experiments 5 and 6, the mixture was held at -78 °C for 3 h by using an acetone/dry ice cooling bath and then was allowed to slowly warm to room temperature overnight with stirring.

When hexane was used as the solvent, a colorless gel formed as a second layer that dissolved when the reaction was quenched with 10 mL of a saturated ammonium chloride solution. The organic layer was separated, combined with three extractions of the aqueous layer with 10-mL portions of ether, and dried over anhydrous sodium sulfate. When THF was used as the solvent, the aqueous layer was saturated with potassium carbonate prior to extraction. After solvents were removed by using a rotary evaporator, GLC analysis was carried out on the residue. Table I summarizes the results of the experiments.

For 1 (X = F), the following new products were isolated by preparative GLC and characterized.

1,1-Bis(dimethylfluorosilyl)-3,3-dimethylbutane, 5: colorless liquid; IR 1256 (SiMe), 869 cm⁻¹ (SiF); ¹H NMR -0.08 (d, *J*(H-F) = 16.6 Hz, 12 H (SiMe₂F)), -0.17 (m, 1 H (methine H)), 0.64 (s, 9 H (*t*-Bu)), 1.20 ppm (d, *J* = 5.2 Hz, 2 H (methylene)); ¹³C NMR -0.69 (d, *J*(C-F) = 16.1 Hz (SiMe)), 12.16 (t, *J*(C-F) = 11.7 Hz (SiCSi)), 28.94 (*t*-Bu methyls), 31.34 (*t*-Bu C), 35.38 ppm (methylene C); MS, *m/e* (relative intensity) 223 (8.2, P - Me), 145 (20.7), 86 (50.8), 77 (80.5), 73 (27.3), 57 (100). Anal. Calcd for C₁₀H₂₄F₂Si₂: C, 50.37; H, 10.14. Found: C, 50.58; H, 10.30.

4-(Dimethylfluorosilyl)-3,3,6,6-tetramethyl-3-sila-1-heptene, 6: colorless oil; IR 1400 (C=C), 1250 (SiCH₃), 850 cm⁻¹ (SiF); -0.18 ¹H NMR (s, 6 H (ViSiMe₂)), -0.15 (d, *J*(H-F) = 16.2 Hz (FSiMe₂)), -0.16 (m, 1 H (methine H)), 0.57 (s, 9 H (*t*-Bu)), 1.21 (d, *J* = 5.1 Hz (methylene H)), 5.2–6.2 ppm (m, 3 H (vinyl H)); ¹³C NMR -3.1 (d, *J*(C-F) = 8.3 Hz (FSiCH₃)), -0.1 and 0.1 (d, *J*(C-F) = 8.2 Hz (vinyl SiCH₃)), 9.8 (d, *J*(C-F) = 12.3 Hz (SiCHSi)), 29.6 (*t*-BuMe), 30.1 (*t*-Bu C), 37.2 (methylene C), 131.3 and 139.1 ppm (vinyl carbons); MS, *m/e* (relative intensity) 246 (4.1), 231 (15.1), 190 (16.3), 189 (44.8), 149 (21.8), 148 (62.3), 134 (12.5), 133 (77.1), 111 (38.7), 97 (100), 73 (27.2). Anal. Calcd for C₁₂H₂₇FSi₂: C, 58.47; H, 11.04. Found: C, 58.64; H, 11.11.

1,1,3,3-Tetramethyl-2,4-dineopentyl-1,3-disilacyclobutanes, 4. The characterization of these compounds has been reported previously.⁷ We report here ¹³C NMR and mass spectral data for them.

***cis*-4:** ¹³C NMR -4.8 and 2.5 (SiMe), 12.8 (ring carbons), 29.3 (*t*-BuMe), 31.3 (*t*-Bu C), 39.8 ppm (methylene carbons); MS, *m/e* (relative intensity) 284 (15.1), 227 (100), 157 (90.6), 141 (91.9), 131 (43.0), 85 (20.9), 73 (76.2), 59 (71.4), 57 (16.4).

***trans*-4:** ¹³C NMR -0.71 (SiMe), 12.2 (ring carbons), 29.3 (*t*-BuMe), 31.4 (*t*-Bu C), 39.8 ppm (methylene carbons); MS, *m/e* (relative intensity) 284 (14.5), 227 (98.3), 157 (94.2), 141 (96.2), 131 (53.2), 99 (28.4), 85 (27.5), 73 (100), 59 (95.2), 57 (62.1), 41 (43.0).

General Method for Trapping Experiments with Cyclopentadiene. A solution prepared as described above of 2.5 mL (22 mmol) of the vinylsilane 1 (X = F or Cl) and 7.7 mL (22 mmol) of *tert*-butyllithium in 50 mL of solvent was stirred at -78 °C for 3 h. After the addition of 2.25 mL (21 mmol) of cyclopentadiene the reaction mixture was allowed to warm slowly to room temperature and was stirred overnight. After hydrolytic workup as described above the residue was analyzed by GLC. The characterization of the products 7 and 8 has been reported.² Results of the several trapping experiments are given in Table II, experiments 10–13.

Trapping Experiments with Methoxytrimethylsilane. To a solution of 25 mmol of vinyldimethylfluorosilane in 60 mL of solvent cooled to -78 °C was added dropwise the appropriate amount of a pentane solution of *tert*-butyllithium. After the solution was stirred at -78 °C for 2.5 h, 25 mmol of methoxytrimethylsilane was added and the mixture was allowed to slowly warm to room temperature. Hydrolytic workup was carried out in the usual way. The results are summarized in Table II, experiments 14–16.

2-Methoxy-1,5,5-trimethyl-3-(trimethylsilyl)-2-silahexane, 9, was separated from the reaction mixture and purified by preparative GLC as a colorless liquid: bp 75 °C (3 torr); ¹H NMR -0.35 (m, 1 H (methine)), -0.19 (s, 9 H (Me₃Si)), -0.12 (6 H (Me₂Si)), 0.62 (s, 9 H (*t*-Bu)), 1.19 and 1.22 (d, 2 H (diastereotropic CH₂)), 3.11 ppm (s, 3 H (OCH₃)); ¹³C NMR -1.37 and -0.85 (q (diastereotropic MeOSi(CH₃)₂)), 0.19 (q (Si(CH₃)₃)), 9.30 (d (SiCHSi)), 29.65 (q (C(CH₃)₃)), 31.41 (s (C(CH₃)₃)), 37.07 (t, (CH₂)), 49.42 ppm (q (OCH₃)). Anal. Calcd for C₁₂H₃₀Si₂O: C, 58.46; H, 12.27. Found: C, 58.64; H, 12.15.

Trapping Experiments with Trimethylchlorosilane, Acetone, and Methyl Iodide. To a solution of 4.8 mL (40 mmol) of 1 (X = F) in 50 mL of hexane, cooled to -78 °C, was added dropwise 7.7 mL (22 mmol) of a *tert*-butyllithium solution in pentane. After the mixture was stirred at -78 °C for 5 h, a solution of 200 mmol of trimethylchlorosilane in 50 mL of THF was added dropwise, and the mixture was allowed to warm to room temperature. Hydrolytic workup gave 1.1% of vinyltrimethylsilane, 49.4% of the dimers 4, 3.6% of 5, 9.6% of 6, and a 9.8% yield of the following:

2-Fluoro-2,5,5-trimethyl-3-(trimethylsilyl)-2-silahexane: colorless liquid; ¹H NMR -0.17 (s, 9 H (SiMe₃)), -0.03 (d, *J*(H-F) = 17.2 Hz, 6 H (SiFMe₂)), -0.19 (m, 1 H (methine H)), 0.63 (s, 9 H (*t*-Bu)), 1.22 ppm (d, *J* = 6.1 Hz, 2 H (methylene H)); ¹³C NMR -0.39 (SiMe₃), 0.68 (d, *J*(C-F) = 10.1 Hz (SiMe₂F)), 10.27 (d, *J*(C-F) = 11.2 Hz (SiCSi)), 29.29 (*t*-BuMe), 31.41 (methylene C), 37.00 ppm (methine C). Anal. Calcd for C₁₁H₂₇FSi₂: C, 56.34; H, 11.60. Found: C, 56.56; H, 11.55.

Attempts To Trap Ethylene. The reactions described in general procedure were carried out with a setup designed so that the reaction flask was swept with dry nitrogen throughout the experiment. The effluent gas was passed by means of a gas dispersion tube through a trap containing a solution of bromine in carbon tetrachloride. The contents of the trap were analyzed by GLC at the end of the 3-h period at -78 °C, after the reaction had warmed to room temperature and after the reaction mixture had been hydrolyzed. No 1,2-dibromoethane was detected. Analysis of the reaction mixtures gave results identical with those for experiments 1 and 3, Table I.

Reactions with *sec*-Butyllithium were carried out as described in the general procedure, giving the results shown in the text. The following compounds were isolated by preparative GLC and characterized.

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(19) Okawara, P.; Sakiyama, M. *Nippon Kagaku Zasshi*, 1955, 58, 805.

3,4,4,5-Tetramethyl-4-silaheptane, 10: colorless liquid; ^1H NMR -0.12 (s, 6 H (SiMe₂)), $0.6-1.5$ ppm (broad envelope, 18 H (*sec*-Bu hydrogens)); ^{13}C NMR -6.57 (q (Si(CH₃))), 13.59 and 13.85 (q (*sec*-Bu methyls)), 20.03 (d (*sec*-Bu methine)), 25.04 ppm (t (*sec*-Bu methylene)); MS, *m/e* (relative intensity) 172 (3), 157 (2), 115 (50), 101 (4), 87 (8), 73 (100), 59 (72). Anal. Calcd for C₁₀H₂₄Si: C, 69.67; H, 14.03. Found: C, 69.83; H, 14.26.

3,4,4,7-Tetramethyl-4-sila-5-nonene, 11: MS, *m/e* (relative intensity) 183 (2, P - Me), 141 (100), 127 (8), 113 (20), 99 (31), 85 (43), 73 (40), 59 (52).

3,4,4,7-Tetramethyl-4-silanonane, 12: colorless liquid; ^1H NMR 0.1 (s, 6 H), $0.7-2.6$ ppm (br, 22 H); ^{13}C NMR -4.94 (q (SiCH₃)), 10.86 , 11.44 , 13.52 , 13.72 , 18.56 , 21.00 , 24.90 , 30.63 , 37.59 ppm; ^{29}Si MS, *m/e* (relative intensity) 185 (2, P - Me), 143 (62), 129 (8), 115 (10), 99 (12), 87 (35), 73 (88), 59 (100). Anal. Calcd for C₁₂H₂₈Si: C, 71.90; H, 14.08. Found: C, 71.73; H, 14.09.

5-(Dimethylfluorosilyl)-3,4,4,7-tetramethyl-4-silanonane, 13: colorless oil; ^1H NMR 0.08 (s, 6 H), 0.25 (d, 6 H, $J(\text{H}-\text{F}) = 13$ Hz), $0.6-2.7$ ppm (br, 21 H); ^{13}C NMR -4.75 and -4.29 (diastereotopic Si(CH₃)₂), -0.52 (d, $J(\text{C}-\text{F}) = 17.6$ Hz) and 0.81 (d, $J(\text{C}-\text{F}) = 16.1$ Hz (diastereotopic SiF(CH₃)₂)), 10.66 , 11.15 , 13.26 , 18.40 , 19.25 , 20.54 , 20.68 , 24.64 , 28.48 , 30.24 , 31.99 , 36.48 ppm; ^{29}Si MS, *m/e* (relative intensity) 261 (2, P - Me), 219 (35), 205 (5), 141 (100), 127 (15), 113 (14), 99 (22), 85 (36), 77 (12), 73 (42), 59 (46). Anal. Calcd for C₁₄H₃₀Si₂F: C, 60.80; H, 12.03. Found: C, 60.92; H, 12.09.

2,4-Bis(2-methylbutyl)-1,1,3,3-tetramethyl-1,3-disilacyclobutane, 14: colorless liquid; ^1H NMR 0.15 (br, 12 H), $0.76-2.6$ ppm (br, 24 H); ^{13}C NMR mixture of 68% *cis*-14 and 32% *trans*-14 estimated from spectrum, -5.14 and 2.79 (q (Si-CH₃ is *cis* isomer)), -0.98 (q (SiCH₃ in *trans* isomer)), 11.44 (CH₃CH₂ of *sec*-Bu), 14.76 (d (ring C in *trans* isomer)), 15.41 (d (ring C in *cis* isomer)), 18.99 (t (CH₃ of *sec*-Bu)), 29.26 (t (methylene of *sec*-Bu)), 32.12 (t (methylene on ring in *cis* isomer)), 32.84 (t (methylene on ring in *trans* isomer)), 37.98 ppm (d, (methine of *sec*-Bu)); MS, *m/e* (relative intensity) 284 (4), 269 (1), 227 (30), 157 (42), 141 (80), 131 (90), 113 (16), 99 (28), 85 (100), 73 (85), 59 (88). Anal. Calcd for C₁₈H₃₆Si₂: C, 67.52; H, 12.75. Found: C, 67.63; H, 12.82.

From the reactions with *n*-butyllithium the following compounds were isolated.

3,3-Dimethyl-3-sila-1-heptene, 15:¹³ ^1H NMR -0.15 (s, 6 H), $0.2-1.3$ (br, 9 H), $5.0-6.2$ ppm (m, 3 H); ^{13}C NMR -3.97 (q

(SiCH₃), 13.13 , 26.08 , and 25.75 (t (CH₂'s of *n*-Bu)), 14.48 (q (CH₃ of *n*-Bu)), 130.51 (d) and 138.51 ppm (t) (vinyl carbons); MS, *m/e* (relative intensity) 142 (1), 127 (6), 114 (8), 99 (4), 85 (100), 71 (38), 59 (70).

5,5-Dimethyl-5-silanonane, 16:¹⁴ ^1H NMR -0.30 (s, 6 H), $0-1.2$ ppm (br, 18 H); ^{13}C NMR -3.77 (q (SiCH₃)), 13.33 , 26.40 , 26.08 , (t (CH₂'s of *n*-Bu)), 14.89 ppm (q (CH₃ of *n*-Bu)); MS, *m/e* (relative intensity) 172 (1), 157 (6), 115 (78), 101 (12), 73 (74), 59 (100).

5,5-Dimethyl-5-silaundecane, 17: ^1H NMR 0.08 (s, 6 H), $0.6-2.6$ ppm (br, 22 H); ^{13}C NMR -3.84 (q (SiCH₃)), 14.89 (q (CH₃ of *n*-Bu)), 13.66 (CH₃ of *n*-hexyl), 22.56 , 23.86 , 26.14 , 26.46 , 31.60 , 32.90 , 33.23 , 33.49 ppm (CH₂ groups); MS, *m/e* (relative intensity) 185 (4, P - Me), 143 (52), 129 (10), 115 (35), 101 (10), 87 (16), 173 (70), 59 (100).

4-*n*-Pentyl-3,3,5,5-tetramethyl-3,5-disila-1-nonene, 18: MS, *m/e* (relative intensity) 231 (6, P - Me), 219 (1), 189 (2), 176 (6), 153 (15), 141 (40), 127 (42), 114 (55), 99 (44), 85 (100), 77 (15), 73 (22), 59 (73).

2,4-Di-*n*-pentyl-1,1,3,3-tetramethyl-1,3-disilacyclobutane, 19: colorless liquid; ^1H NMR 0.15 (s, 6 H), 0.17 (s, 6 H), $0.6-2.6$ ppm (br, 24 H); -3.71 and -3.51 (q (SiCH₃)), 13.66 and 14.63 (q (CH₃ or *n*-Bu)), 13.98 and 14.89 (d (CH in ring)), 22.63 , 23.47 , 24.40 , 26.60 , 28.22 , 28.74 , 29.07 , 32.38 ppm (t (CH₂ groups)); MS, *m/e* (relative intensity) 227 (18, P - Bu), 213 (3), 199 (2), 171 (4), 153 (18), 141 (48), 131 (88), 115 (14), 99 (12), 85 (55), 73 (52), 59 (100).

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Registry No. 1, X = F, 38755-76-9; 1, X = Cl, 1719-58-0; *cis*-4, 62518-77-8; *trans*-4, 62518-76-7; 5, 87656-63-1; 6, 87656-64-2; 9, 87656-65-3; 10, 87656-66-4; 11, 87681-17-2; 12, 87656-67-5; 13, 87656-68-6; *cis*-14, 87656-69-7; *trans*-14, 87656-72-2; 15, 24343-24-6; 16, 996-06-5; 17, 80054-50-8; 18, 87656-70-0; 19, 87656-71-1; 2-fluoro-2,5,5-trimethyl-3-(trimethylsilyl)-2-silahexane, 87681-18-3; *tert*-butyllithium, 594-19-4; *sec*-butyllithium, 598-30-1; *n*-butyllithium, 109-72-8; antimony trifluoride, 7783-56-4; antimony pentachloride, 7647-18-9; cyclopentadiene, 542-92-7; methoxytrimethylsilane, 1825-61-2; trimethylchlorosilane, 75-77-4; acetone, 67-64-1; methyl iodide, 74-88-4.

(20) Because of the large number of diastereotopic protons in the molecule, the off-resonance proton-decoupled spectrum was extremely complex and all of the carbon resonances were not assigned.

Efficient Syntheses of New Fulvalene-Bridged Carbonyl Complexes of Cobalt, Ruthenium, Chromium, Molybdenum, and Tungsten

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A variety of new dimetallafulvalene carbonyl complexes have been prepared by slow addition of cold purified dihydrofulvalene in heptane to boiling solutions of metal carbonyls. Reaction of Co₂(CO)₈ with dihydrofulvalene allows efficient preparation of (η^5 : η^5 -C₁₀H₈)(CO)₄Co₂, Ru₃(CO)₁₂, Cr(NCET)₃(CO)₃, Mo(CO)₆, and W(NCET)₃(CO)₃ react to form the intramolecularly metal-metal bonded complexes (η^5 : η^5 -C₁₀H₈)(CO)₄Ru₂ and (η^5 : η^5 -C₁₀H₈)(CO)₆M₂ (M = Cr, Mo, and W). Attempts to generate the analogous iron complexes were unsuccessful. Reaction of a mixture of Ru₃(CO)₁₂ and Mo(CO)₆ with dihydrofulvalene affords a better than statistical yield of the mixed metal-metal bonded complex (η^5 : η^5 -C₁₀H₈)(CO)₅MoRu.

Introduction

Cyclopentadienylmetal carbonyl dimers and their derivatives are among the most extensively studied classes

of organometallic compounds. Dinuclear metal complexes are often postulated as simple models with which to study the interactions of molecules with metal surfaces.¹ Cy-